

REQUESTOR CONTACT INFORMATION					
Date: March 3, 2015		Effective term of request (Semester-Year): Fall 2014			
Name: Katy Ho	Tit	e: VCAA			
Campus: Honolulu CC	Off	ice/Department:	Academic Affairs		
Phone: 845-9158	Em	ail: katyho@haw	aii.edu		
1. PROGRAM CODE, MAJOR CODE, CONCENTRATION CODE			Banner forms: S	MAPRLE, SOAGU	JRR, ŠTVMAJR
Institution: Honolulu CC (HON) College: CC)		Department: FT		
✓ New program code ☐ Change/replace existing program	code: CO-FT	-CG (Computerize	ed Grading, Marking,	and Patternmak	ing)
Level: Indergraduate Graduate First-Profession	onal Pos	t-Baccalaureate	Other:		
Degree: Certificate: Certificate		te of Competence			
If requesting an existing Major code and/or Concentration cod	le in Banner:				
Existing Major: FT Fashion Technology Description Fashion Technology		sting Concentratio	on: Code	Description	
If requesting a new Major code or Concentration code the	nat does not e	exist in Banner:			
New Code [4 char/space limit]: CGMP Descri	iption [30 char	/space limit]: Com	p Grading Markin	g & Ptrnmkg	
If a similar major/concentration code exists in Banner, please lis	st the code:				
Is this major/concentration code being used the same way at ot	ther UH camp	uses?			
Is 50% or greater of the classes in this program offered at a loca			pus? Yes V N		reement impact)
Is this program/major/certificate financial aid eligible? Yes V No (Financial Aid Officer consultation required for all new program coo					
Should this program be available for applicants to select as their planned course of study on the online application? [If yes, students may select the code as their only program of study]					

Replacing or eliminating an existing program code:	-			
If replacing an existing program code, are current stude	nts "grandfathered" u	nder the old	d code? 🔲 Yes 🔲 No	
Should the old program code be available for use in Bar	nner? 🗌 Yes 📗 I	No		
Online Recru Admis Gener	er Module Application itment sisions al Student emic History	No	Ending Term (Semester-Year)	
2. CERTIFICATES ONLY:				
Does this certificate qualify as a Gainful Employment Pr (Please consult your Financial Aid Officer or see: http://www.ifap.ec	• •		· · · — —	
For new certificates approved by the Chancellor, the re	ated BOR authorized a	icademic pr	ogram is: AAS-FT	
3. NEW CAMPUS, COLLEGE, DIVISION, OR DEPARTMEN	IT CODE		Banner forms: STVCAMP, STVCOLL, STVDIVS, STVDEPT	
Campus code [3 char]:	Campus description	[30 char/spac	ce limit]:	
College code [2 char]:	College code [2 char]: College description [30 char/space limit]:			
Division code [4 char/space limit]: Division description [30 char/space limit]:				
Department code [4 char/space limit]:	Department code [4 char/space limit]: Department description [30 char/space limit]:			

4. NEW COURSE SUBJECT CODE (Subject Alpha)	Banner form: STVSUBJ		
College:	Department:		
Subject code [4 char/space limit]:	Subject description [30 char/space limit]:		
5. NEW MINOR (Minor codes are listed on the Major code to	able) Banner form: STVMAJR		
Minor Code [4 char/space limit]:	Minor Description [30 char/space limit]:		
Please briefly describe your request and explain why	y you are requesting the code(s):		
	odify the Certificate of Completion to a Certificate of Competence (CO) in response to the		
Community College system's decision to eliminate the Ce	ertificate of Completion. An Academic Program code was not created at that time.		
SUPPORTING DOCUMENTATION			
Please see the Code Request Guide for the required	supporting documents to be submitted. Documents submitted with this form:		
☐ Board of Regents meeting minutes and supp	orting documents provided to the BOR		
Memo from UH President			
Memo from Chancellor via curriculum action			
Curriculum (required for requests for new pr	rograms/majors/minors/certificates)		
Gainful Employment Program notification to	the US Department of Education		
Other:			

CAMPUS VERIFICATION	
Requestor Signature YUMW	Date 3 13 15
Registrar (If different from Requestor) Josephine Stenberg	Theren 3/16/15
Print name Signature Email/memo in lieu of Registrar's signature may be attached	Date
Financial Aid Officer (Financial Aid Officer consultation required for all new program co	odes) LUMA 03/28/2015
Print name Signature Email/memo in lieu of Financial Aid Officer's signature may be a tached	Date
For Community Colleges, verification of consultation with OVPCC Acad	demic Affairs:
Suzutto Robum Print name Email/memo in lieu of signature may be attached Suzut Robum Signature Signature	3/30/15 Date

Send completed form and supporting documentation to:

Institutional Research and Analysis Office (IRAO)

1633 Bachman Place

Email: iro-mail@lists.hawaii.edu

Sinclair Annex 2, Room 4 Honolulu, HI 96822 Fax: 808-956-9870 Phone: 808-956-7532

After <u>all</u> required forms and supporting documents have been submitted, please allow at least two weeks for processing by IRAO and Banner Central.

FOR INTERNAL USE ONLY	Date form/docs received:	
Program code [12]:	Program Description [30]:	
CIP code [6]:	CIP description [30]:	



March 16, 2015

MEMORANDUM

TO:

Risa Dixon

Vice President for Academic Affairs

FROM:

Erika Lacro

Chancellor

SUBJECT:

Program Actions at Honolulu Community College

I had approved the following program actions in January 2014 and February 2015.

New

Certificate of Achievement (effective Fall 2015) CA-FIRE-ER (Emergency Medical Response)

Certificate of Competence (effective Fall 2014)
CO-ECED-CDA
CO-FT-CG (Computerized Grading, Marking, and Patternmaking)
CO-FT-CR (Cutting Room Functions)
CO-FT-FP (Flat Patternmaking)

c: Pearl Iboshi, IRAO

'University of Hawai'i Honolulu Community College

CURRICULUM ACTION PROPOSAL Modify a Program

Program Name:	Fashion Technology	Proposer: Joy Ann Nagaue	Effective Term: Fall 2014
Division:	11		
Department:	Fashion Technology		

Department: Fashion recnnology	
PROPOSAL SUMMARY (Include reasons for modifying program.):	
This program modification proposes to eliminate Fashion Technology's Certificate	of Completion due to a system wide decision to no longer
offer it.	

SIGNATURES	
Proposal: Proposal Authorization/Date Authorization/Date	3 (/r4

University of Hawai'i Honolulu Community College CURRICULUM ACTION PROPOSAL

Modify a Program

ogram Name: Fashion Techn	ology		Effective Term: Fall 2014
Z. Attach photo	OCODIES Of all Catalog pages that are affected	t with changes marked	
	EXISTING		PROPOSED
			
Program Description:			
Program SLO:			
Program Requirements:	Prerequisite: Prerequisite or Co-requisite:		or Co-requisite:
D		Other Require	ement:
	Certificate of Completion	Eliminate Cer	tificate of Completion
Credits:			
Course Sequence:	(Attach)	(Attach)	
Minimum Credits Required:			
Other:			
Program Liaison:			
Vebsite:		,	
Address/Location:			
aculty:			
Cost of Textbooks/Supplies:			<u> </u>
☐YES ⊠NO Are any COUF	RSES impacted by this proposal? If "Yes"	describe below.	
	Attach phot 3. If the Program Program Name, Alpha: Program Mission: Program Description: Program SLO: Program Requirements: Degrees & Certificates: Course Addition: Course Deletion: Credits: Course Sequence: Minimum Credits Required: Other: Program Liaison: Website: Address/Location: Faculty: Cost of Textbooks/Supplies: Advisory Committee: TYES NO Are any PROCUTES NO Are any COURTER Attach phot 2.	Attach protocopies or all Catalog pages that are affecter. If the Program Modification requires course changes, att EXISTING Program Name, Alpha: Program Mescription: Program Requirements: Prerequisite: Prerequisite or Co-requisite: Recommended Prep: Other Requirement: Course Addition: Course Deletion: Credits: Course Sequence: (Attach) Minimum Credits Required: Other: Program Liaison: Mebsite: Address/Location: Caculty: Cost of Textbooks/Supplies: Advisory Committee: YES NO Are any PROGRAMS impacted by this proposal? If "Yes"	Structions: 1. Complete only items being modified. Continue overflow text under "Additional Infor 2. Attach photocopies of all Catalog pages that are affected with changes marked. 3. If the Program Modification requires course changes, attach applicable Course Modification requires course requirements: Prerequisite:

Rev. Sept 2012

LIAISON: Joy Nagaue (845-9203, jnagaue@hawaii.edu)

WEBSITE: http://tech.honolulu.hawaii.edu/ft

FACULTY: Joy Nagaue

PROGRAM Mission: The Fashion Technology program's mission is to serve the community as a learning-centered, open door program that provides technical training to meet the demands of the fashion industry and the needs of the individual. An open-exit option allows the students to identify their career objectives and participate in program exploration.

PROGRAM DESCRIPTION: The curriculum is designed to provide competency for a wide range of occupations in the fashion industry. Theoretical knowledge and practical skills are applied in clothing construction, industrial sewing, flat patternmaking, designing, textiles, fashion sketching, grading, marking and cutting, and computerized grading and marking. Internship or



FT student drapes a mannequin.

cooperative education experiences are available to interested students. This broad background enables students to select various occupations such as designer, patternmaker, cutter, or custom dressmaker.

The program offers an Associate degree, and Certificates of Achievement. Completion and Competence. Faculty members assist students in selecting the courses related to their talents and interest.

PROGRAM STUDENT LEARNING OUTCOMES (SLO): Upon successful completion of the FT program, students will be able to:

- Design and sketch appropriate garment designs suitable to the market or customer.
- Select appropriate fabrics and notions suitable to the garment's design.
- Drape, draft or manipulate flat patterns to create accurate garment patterns.
- Lay perfected patterns correctly and economically onto markers or fabric.
- Cut fabric using appropriate tools, including power tools.
- Construct garments using various sewing techniques.
- Fit garments on various body types and be able to make the proper adjustments.
- · Grade the finished patterns into various sizes.
- Present the garments in a professional manner to "sell" the designs.
- Define the fashion industry's manufacturing process.

PROGRAM REQUIREMENTS:

Program Prerequisites: MATH 9, OR Placement in MATH 50.or higher Black Mark 1000 acc		Certificate of Completion	Certificate of Achievement <u>Credits</u>	Associate in Applied Science Degree Credits
First Semester	Sighe	a í		
FT 111	Art and Design in Fashion *	2	3	3
FT 205	Clothing Construction Methods	#	4	4
FT 215	Flat Patternmaking l	3	3	3
FT 200	Culture, Gender and Appearance *			3
MATH 100 or Higher	Survey of Mathematics			3
•		10	10	16
Second Semester	•			
FT 28	Introduction to Industrial Sewing	\$	3	3
FT 40	Fabric Analysis	1	3	3
FT 216	Fashion Design and Sketching	{	3	3
FT 217	Flat Patternmaking II	3	3	3
FT 237	Pattern Grading	(_ 3
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Third Semester				
FT 29	Textile Art		3	3
FT 36	Draping		3	3
FT 43	Cutting Room Functions		3	3
FT Electives	(highly recommended) **			
FT 41	Apparel Design			3
FT 160	Computer Aided Digitizing, Grading & Marking			3
	_	- ~-	9	15
Fourth Semester	•			
FT 30	Basic Creative Designing	.)	3	3
FT Elective *	**	Ì	9	3
General Edu	cation Requirements*)		9
		3	12	15
	Minimum Credits Required	22	43	61

General Education Requirements for the AAS degree are listed under DEGREES AND CERTIFICATES.

(15 credits required.)
FT Electives: 9 credits required (FT 32, 34, 38, 41, 90, 100, 125, 160, 298, 93V or 193V)

(2 FT 298 is an experimental #)

Flat Patternmaking

Program	Prerequisite: FT 28 or demonstrated ability	Certificate of Competence Credits
FT 215	Flat Patternmaking I	3
FT 217	Flat Patternmaking II	3
FT 237	Pattern Grading	3
		9

Cutting Room Functions			Certificate of Competence Credits
FT 43	Cutting Room Functions		3
FT 28	Introduction to Industrial Sewing		3
FT 215	Flat Patternmaking l		3
	•		9:

Computerized Grading, And Marking, and Pattern making

Program Prerequisites: Certificate of FT 43 and 237 or demonstrated ability **Competence Credits** FT 160 Computer Aided Digitizing, Grading and Marking
FT 170 Computer Aided Digitizing, Grading and Marking
FT 170 Computer Aided
Pattern

Computer 2ed July

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